



Atomic Layer Deposition for Materials-Based H₂ Storage: Mg(BH₄)₂ as a case study

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Thomas Gennett,^{a,c} Steven T. Christensen^a

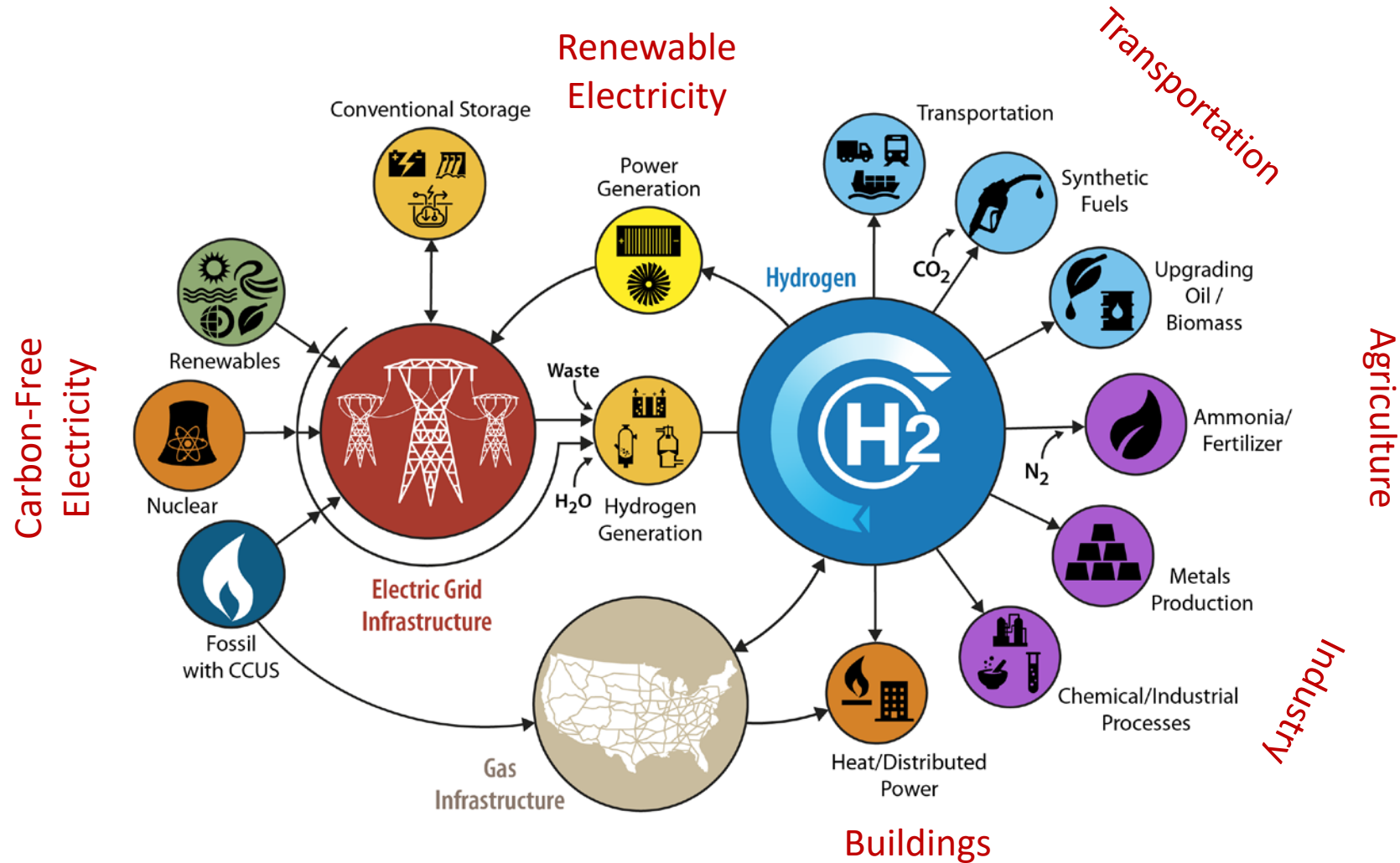
ASE Summit: June 9th-11th, 2021

a: National Renewable Energy Laboratory; Golden, CO

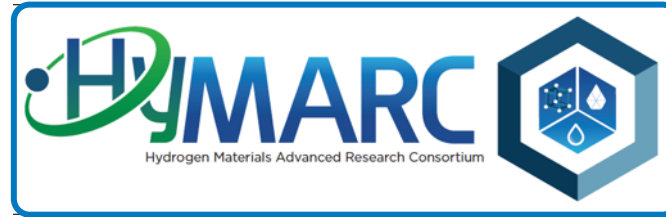
b: SLAC Accelerator Laboratory; Menlo Park, CA

c: Colorado School of Mines; Golden, CO

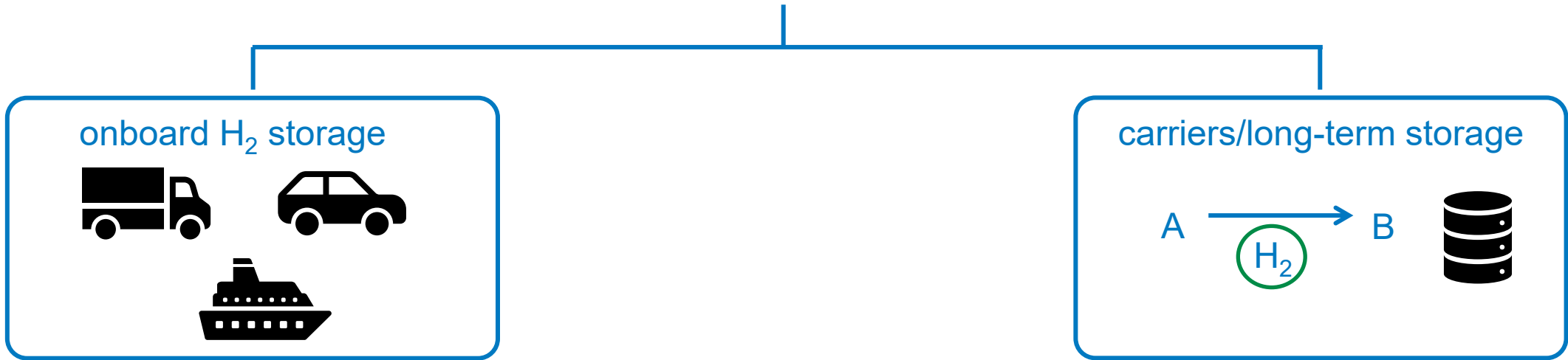
A future built on renewable energies relies on hydrogen storage



The Hydrogen Materials - Advanced Research Consortium (HyMARC)

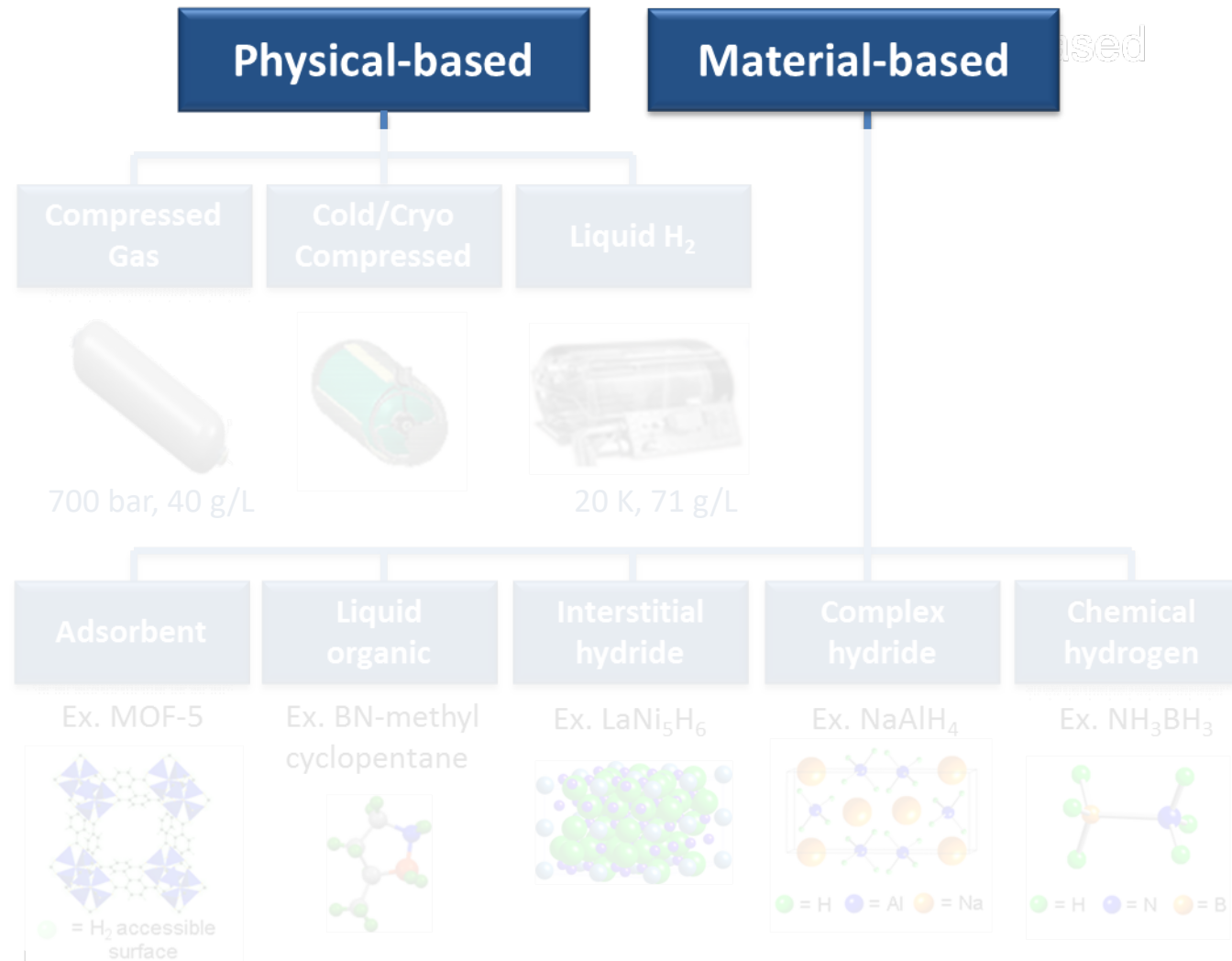


Enabling twice the energy density for onboard H₂ storage

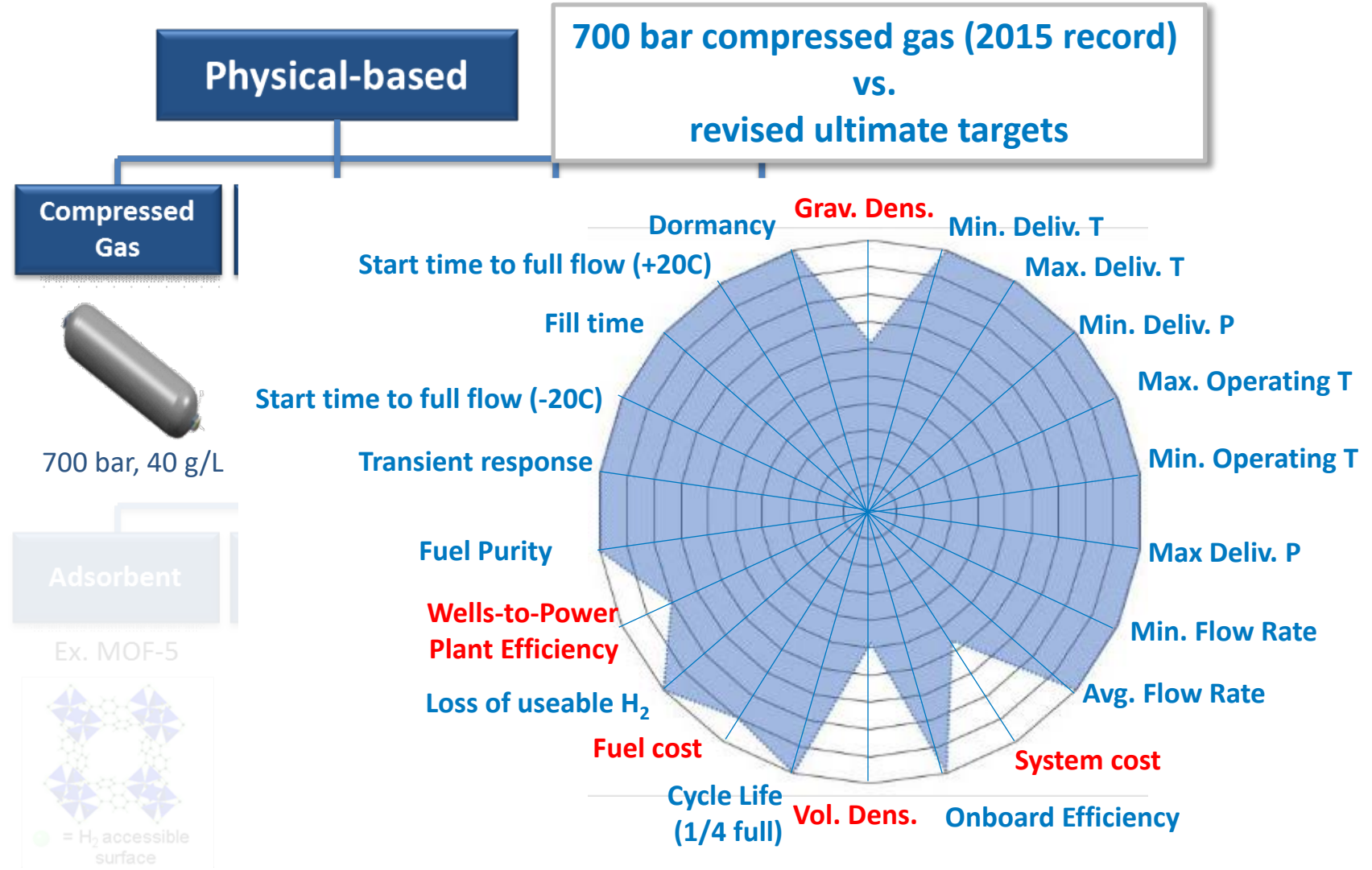


Addresses Key Challenges to Hydrogen Storage in
Advanced Materials Through a Multi-Lab Collaboration

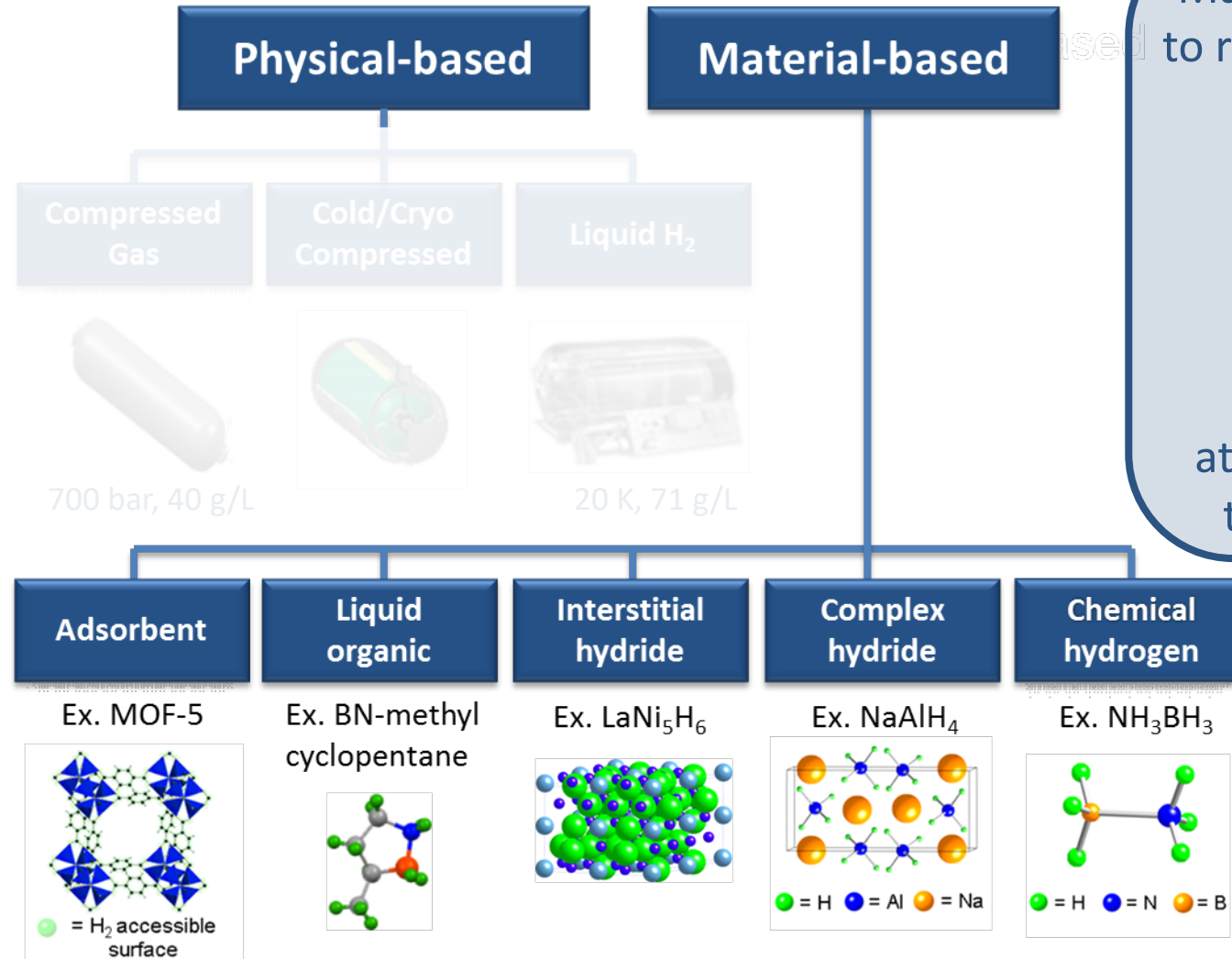
Hydrogen storage technologies



Hydrogen storage technologies



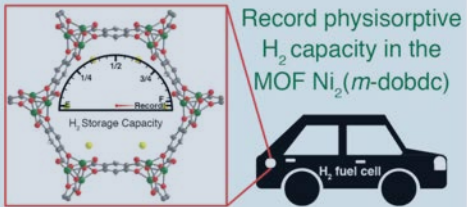
Hydrogen storage technologies



Materials have the potential to reach DOE targets for light-duty vehicles:

- 4.5 H₂ wt%
- $p < 100$ bar
- $-40^{\circ}\text{C} < T < 40^{\circ}\text{C}$

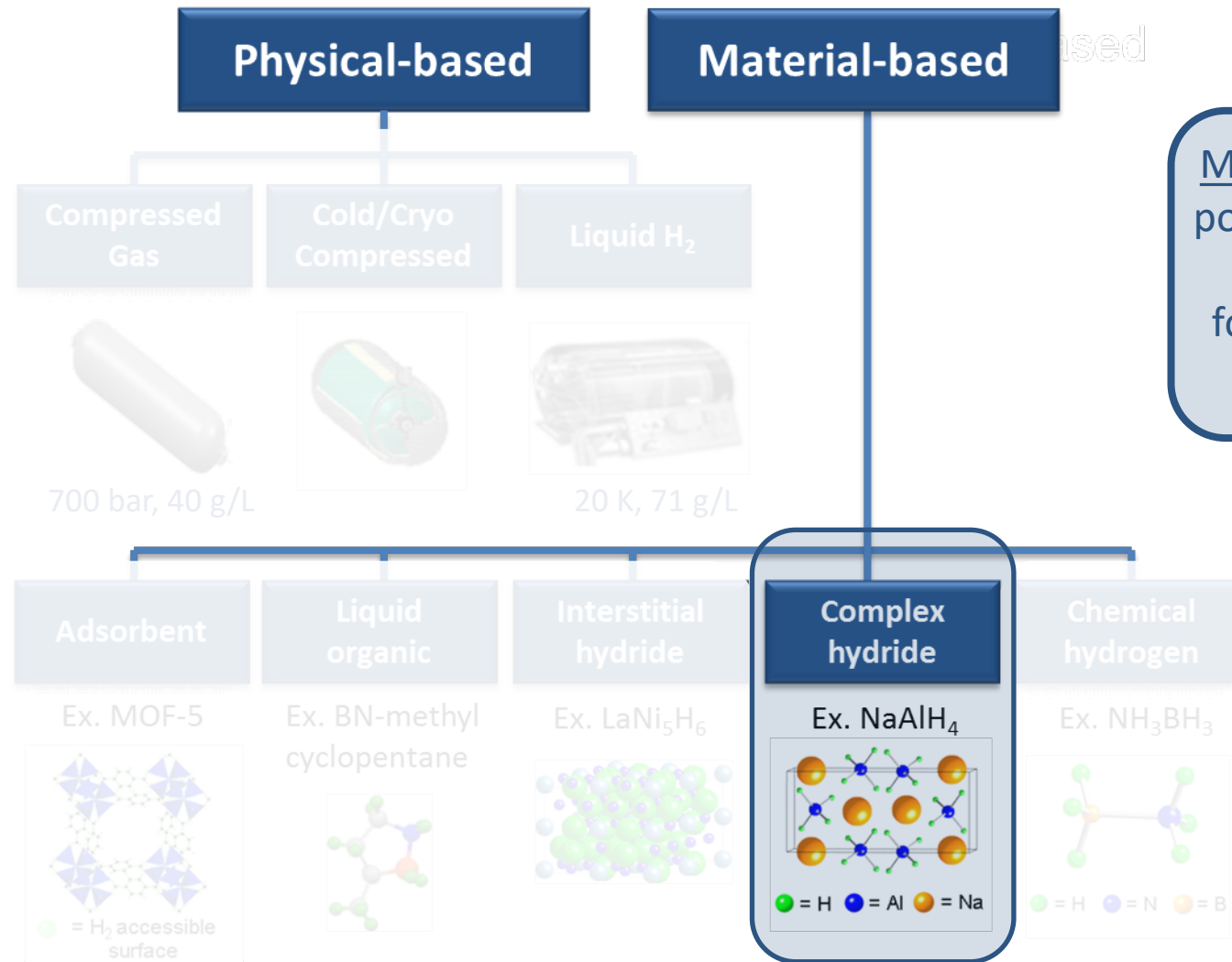
at lower system costs than the 700 bar technology.



HyMARC has the world record room temperature sorbent (11g/L)

Kapelewski et al., *Chem. Mater.* 2018, 30, 22, 8179–8189

Complex hydride: $\text{Mg}(\text{BH}_4)_2$



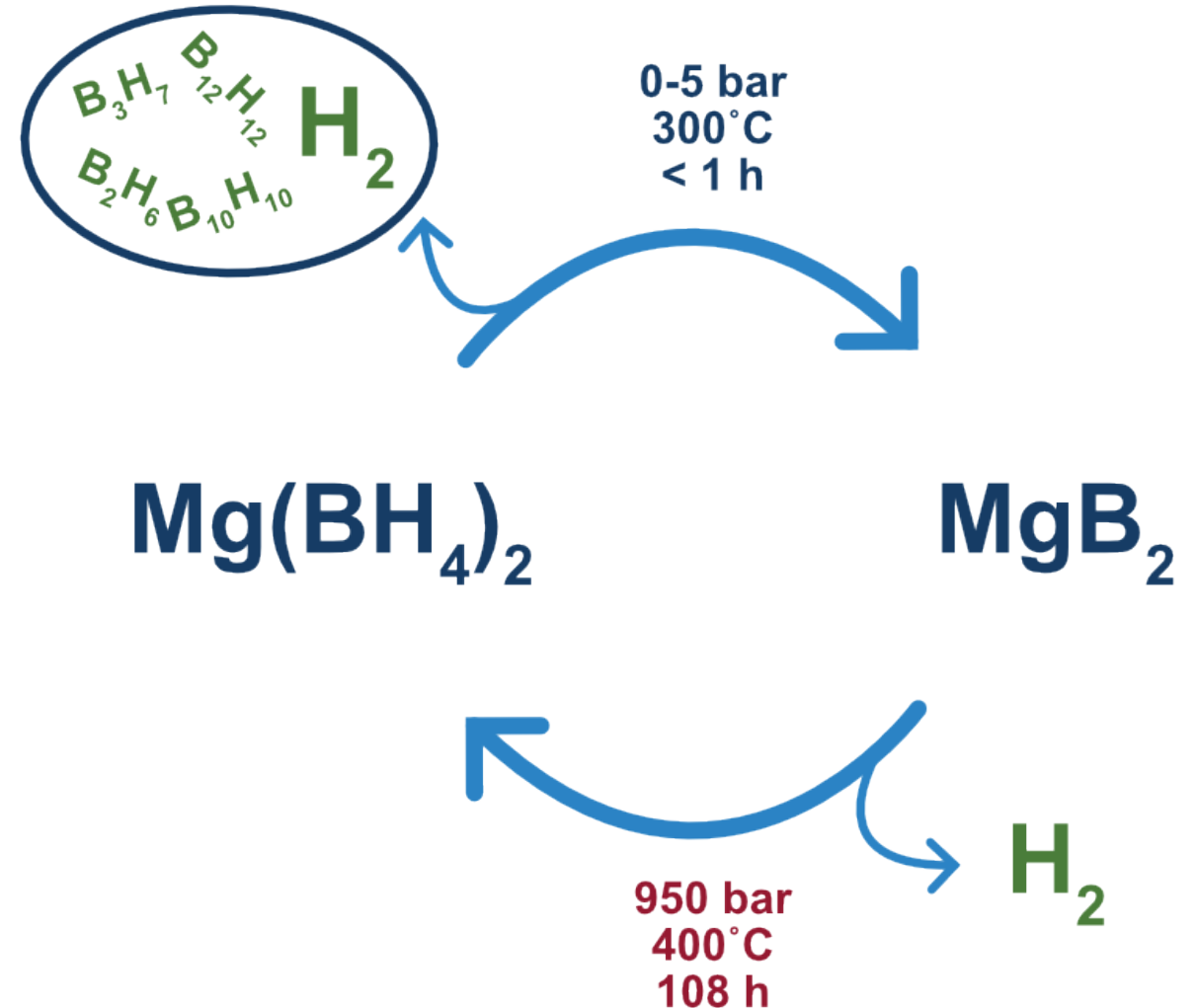
Material used in this work:
porous and nanostructured
 $\gamma\text{-Mg}(\text{BH}_4)_2$
for increased H_2 diffusion
and reaction rates

Mg(BH₄)₂ vs. DOE targets

- Exceeds DOE targets:
 - Volumetric H₂ capacity (82 g/L)
 - Gravimetric H₂ capacity (14.9 wt%)

[Y. Filinchuk et al., Angew. Chem. Int. Ed. \(2011\), 50, 11162–11166](#)

- Requires improvements:
 - Kinetics
 - Reversibility:
 - Suppression of B₂H₆ liberation: fuel cell damage and material loss
 - Suppression of B₁₂H₁₂ formation: thermodynamic energy well
 - Desorption temperature: 300°C for neat material



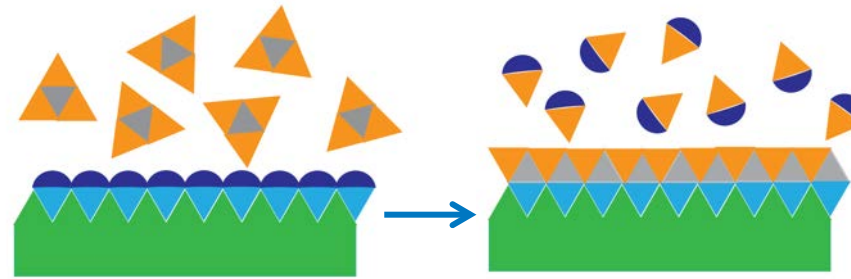
[N. Leick et al., ACS Appl. Energy Mater. 2021, 4, 2, 1150–1162](#)

[G. Severa et al., Chem. Commun., 2010, 46, 421-423](#)

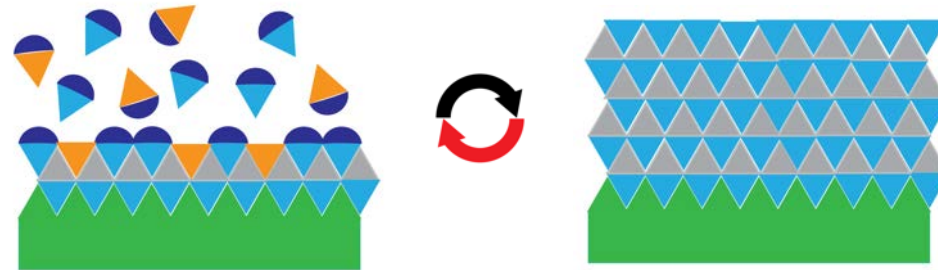
Approach: Additives through atomic layer deposition (ALD)

- **Coating** retains the $\text{Mg}(\text{BH}_4)_2$ nanostructure for cyclability
- **Atomically thin** to maintain the gravimetric capacity of $\text{Mg}(\text{BH}_4)_2$
- **Manipulation** of the thermodynamic pathway for H_2 release
- **Mitigate** material loss
- **Catalyst additive** to enhance reaction rates

Room temperature ALD
to prevent phase change and
 H_2 release of $\gamma\text{-Mg}(\text{BH}_4)_2$

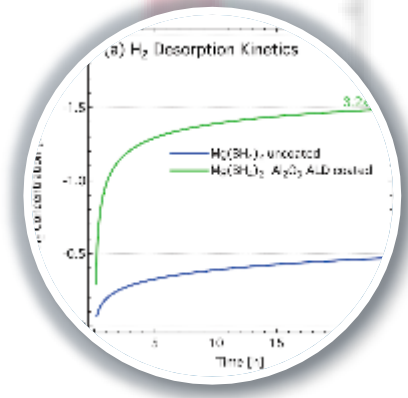


Al-precursor:
8 s
Trimethylaluminum
(TMA, $\text{Al}(\text{CH}_3)_3$)

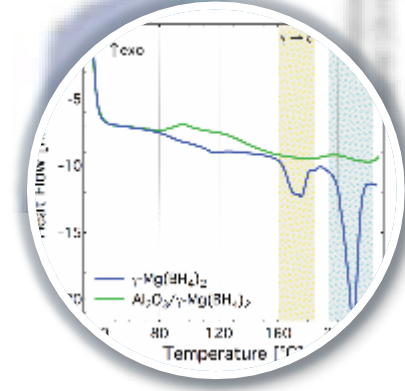


O-Precursor:
8 s
Water (H_2O)

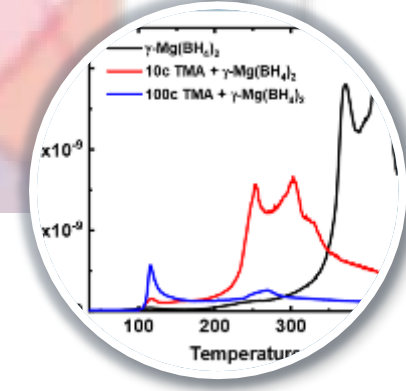
Approach to improve the performance of $\text{Mg}(\text{BH}_4)_2$



ALD of Al_2O_3 :
TMA + H_2O



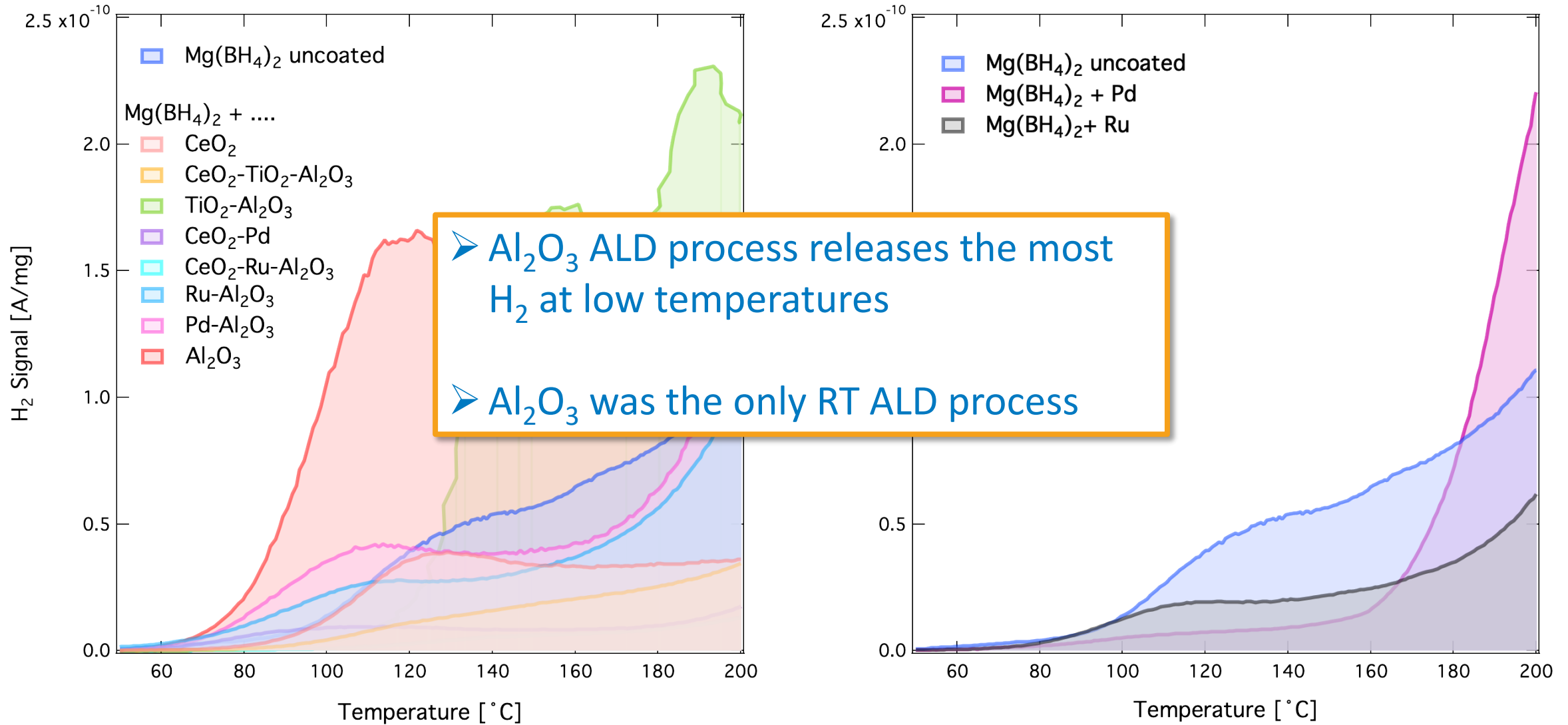
H_2O pulsing only



TMA pulsing only

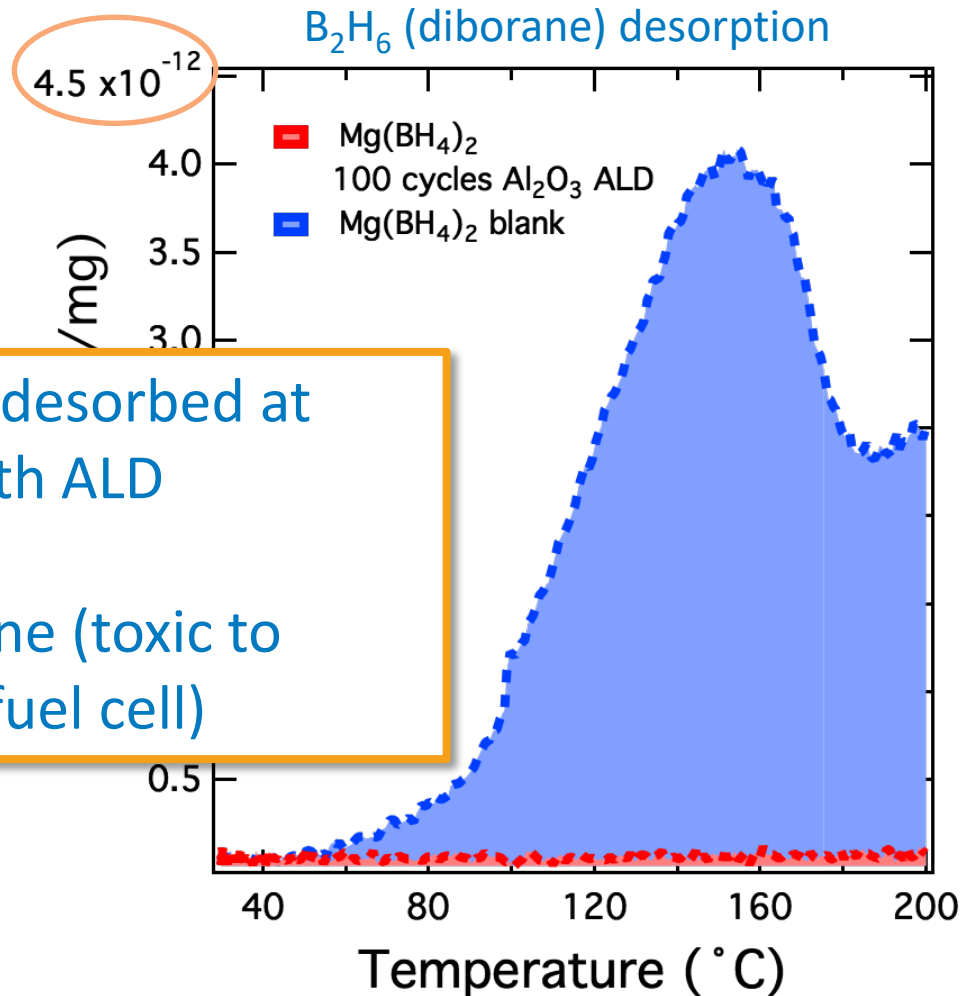
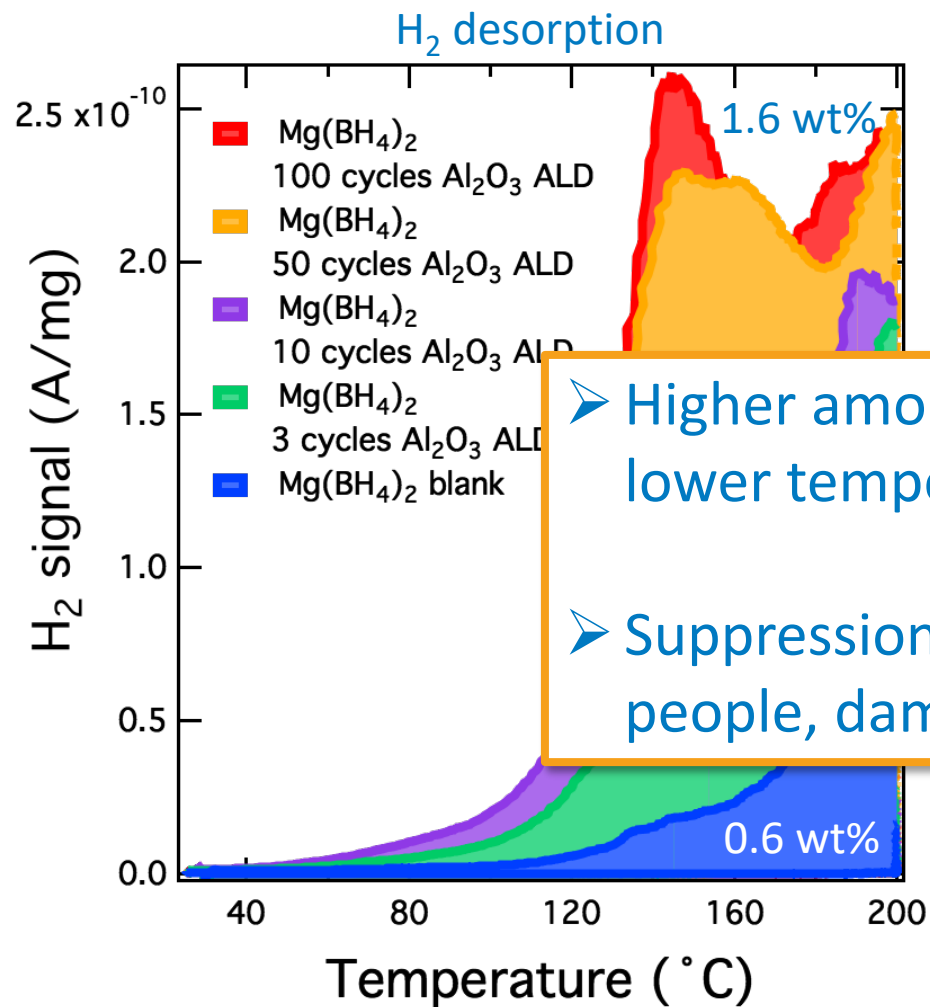
Mg(BH₄)₂ + ALD

Temperature Programmed Desorption



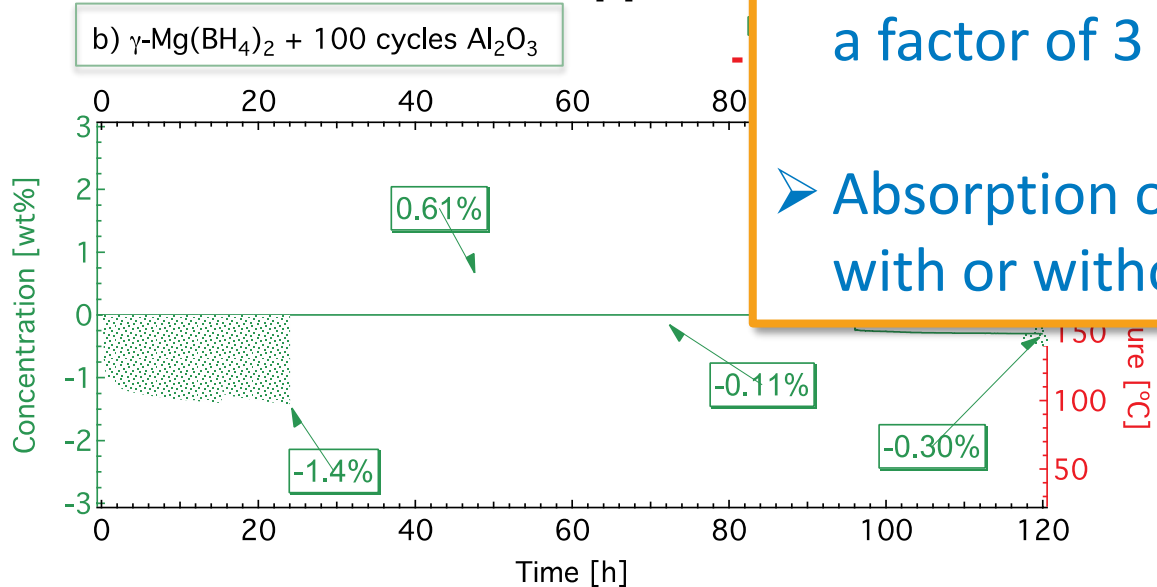
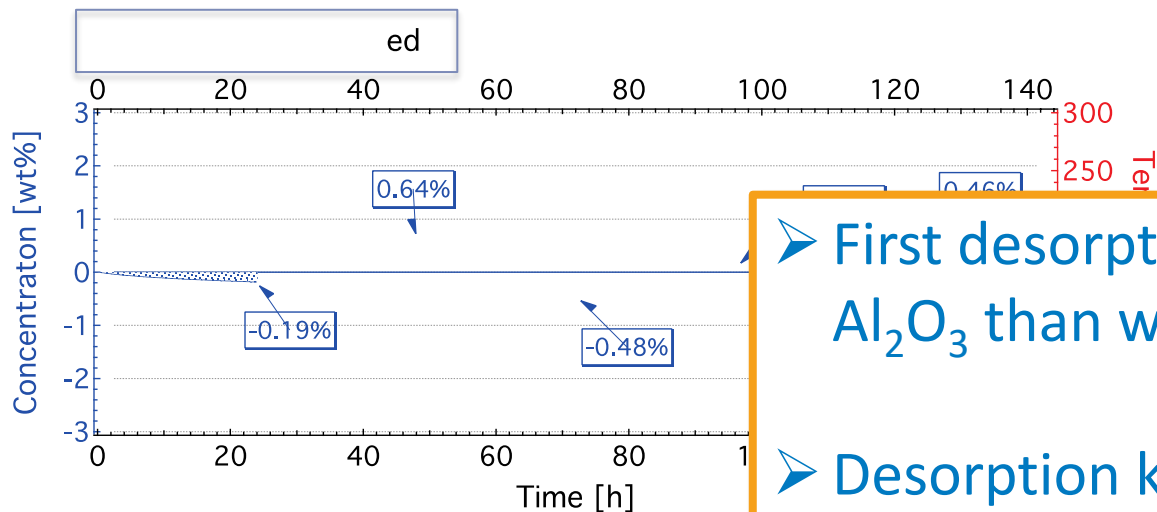
Mg(BH₄)₂ + ALD of Al₂O₃

Temperature Programmed Desorption

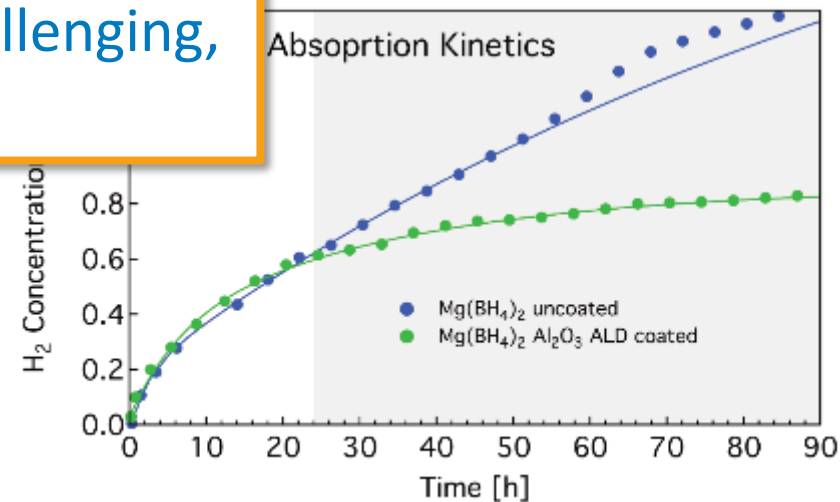
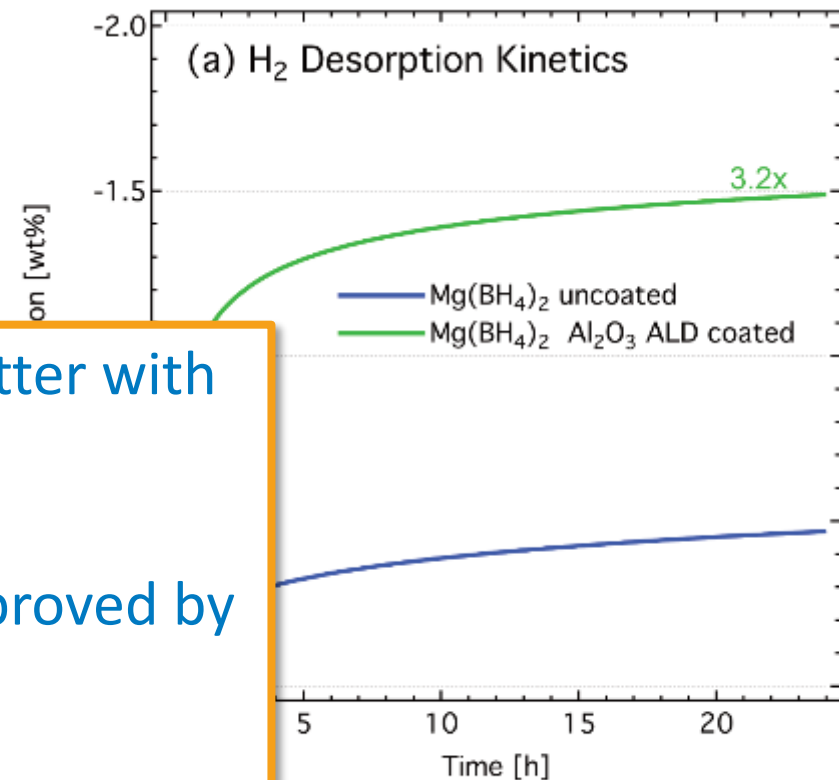


- Higher amounts of H₂ desorbed at lower temperature with ALD
- Suppression of diborane (toxic to people, damages the fuel cell)

Mg(BH₄)₂ + ALD of Al₂O₃

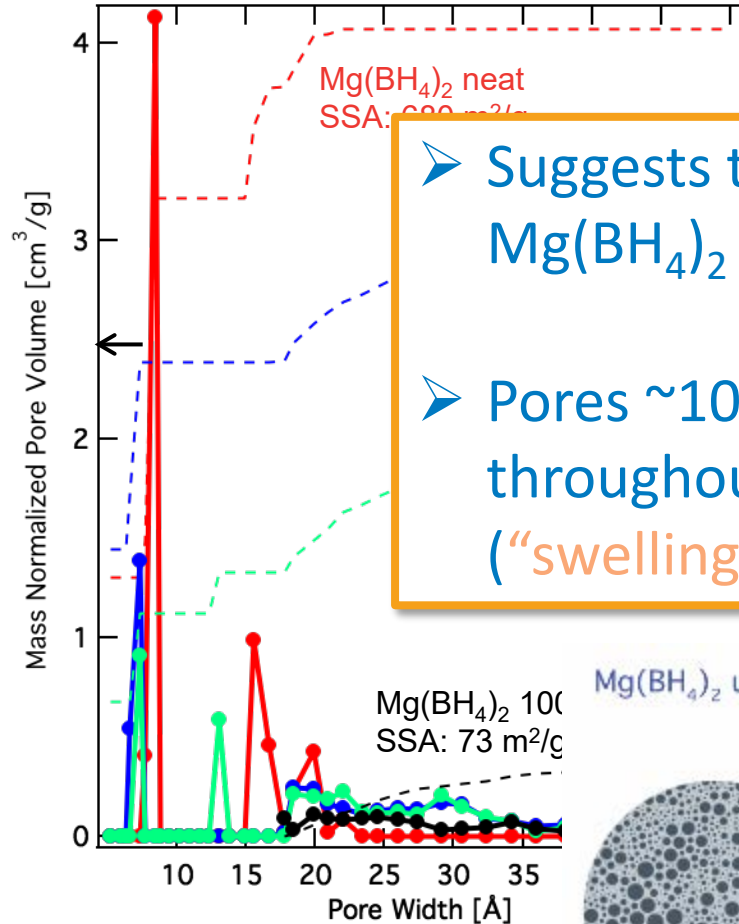


- First desorption performs better with Al₂O₃ than without it
- Desorption kinetics were improved by a factor of 3
- Absorption of H₂ remains challenging, with or without Al₂O₃ ALD

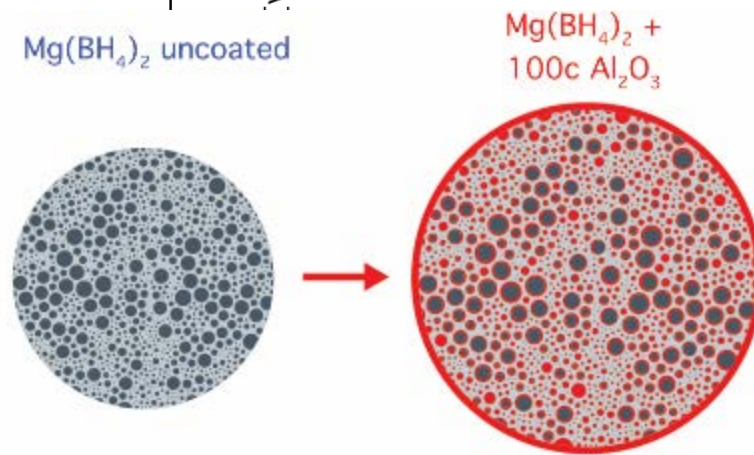


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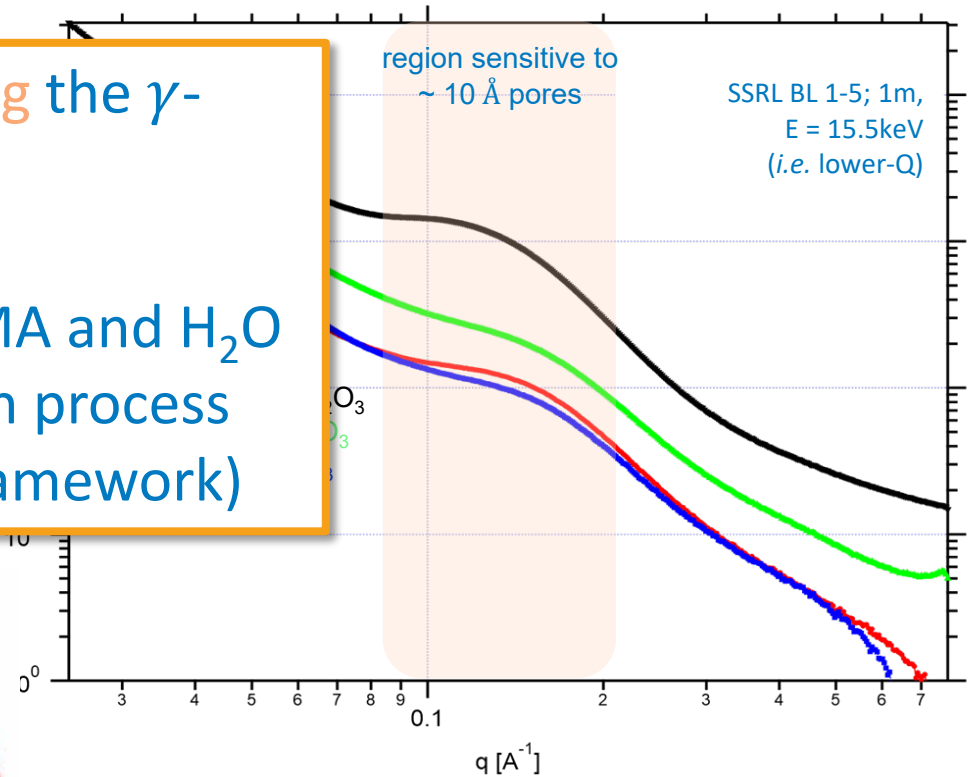
Porosimetry based on N₂ physisorption



- Suggests the coating is **infiltrating** the γ -Mg(BH₄)₂ pore structure
- Pores ~ 10 Å are accessible to TMA and H₂O throughout the entire deposition process (“**swelling**” of the γ -Mg(BH₄)₂ framework)

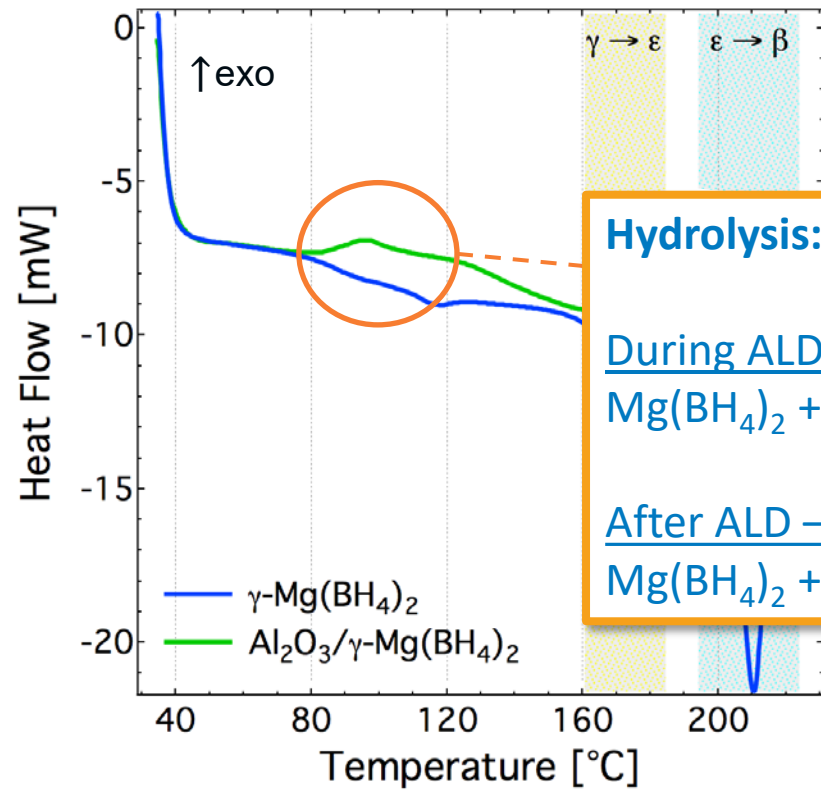


Small angle X-ray spectroscopy on Al₂O₃ ALD-coated γ -Mg(BH₄)₂



Mg(BH₄)₂ + ALD of Al₂O₃

Differential Scanning Calorimetry



Hydrolysis:

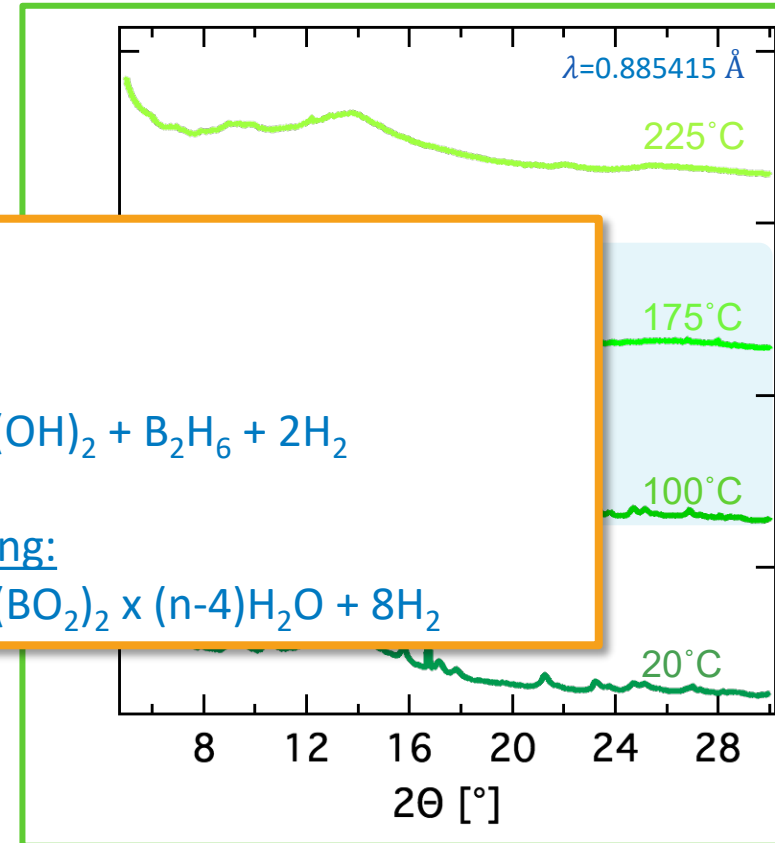
During ALD:



After ALD – during heating:

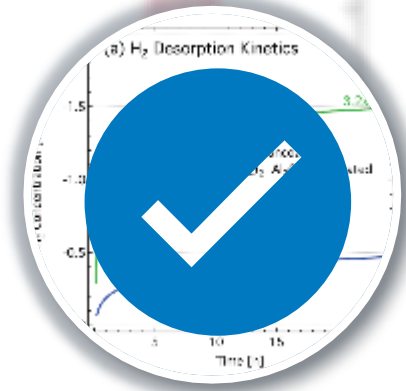


X-Ray Diffraction - *in situ* heating

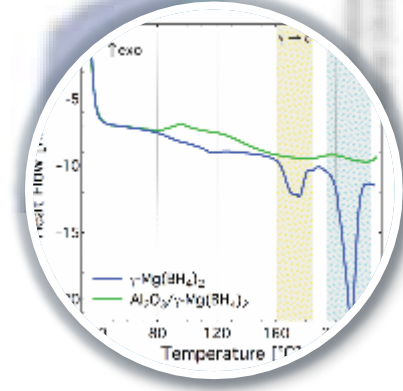


loss of crystalline structure

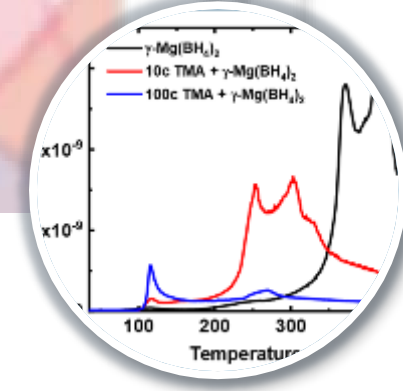
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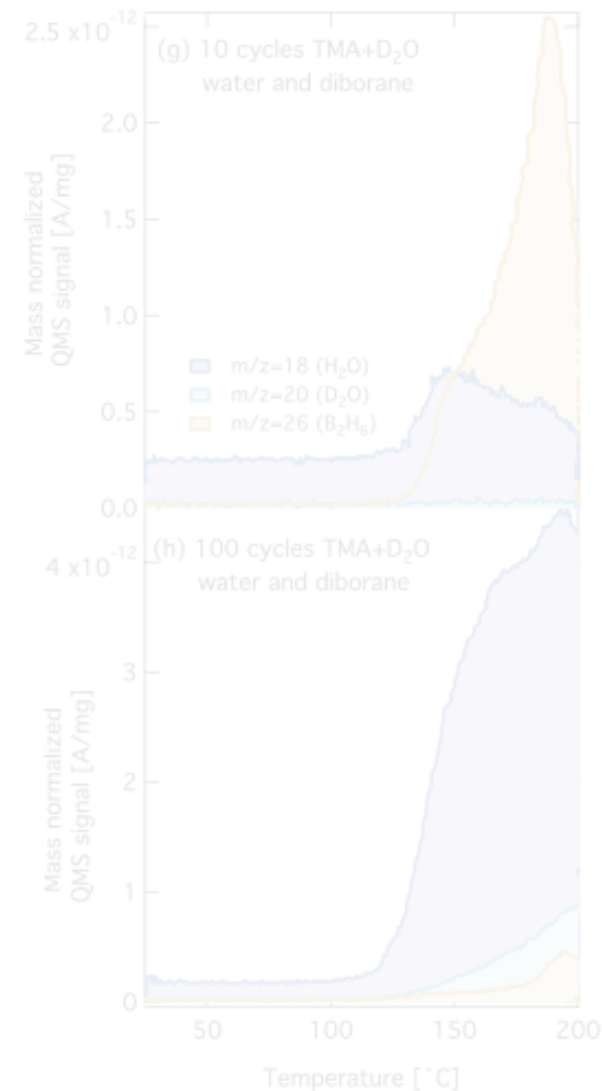
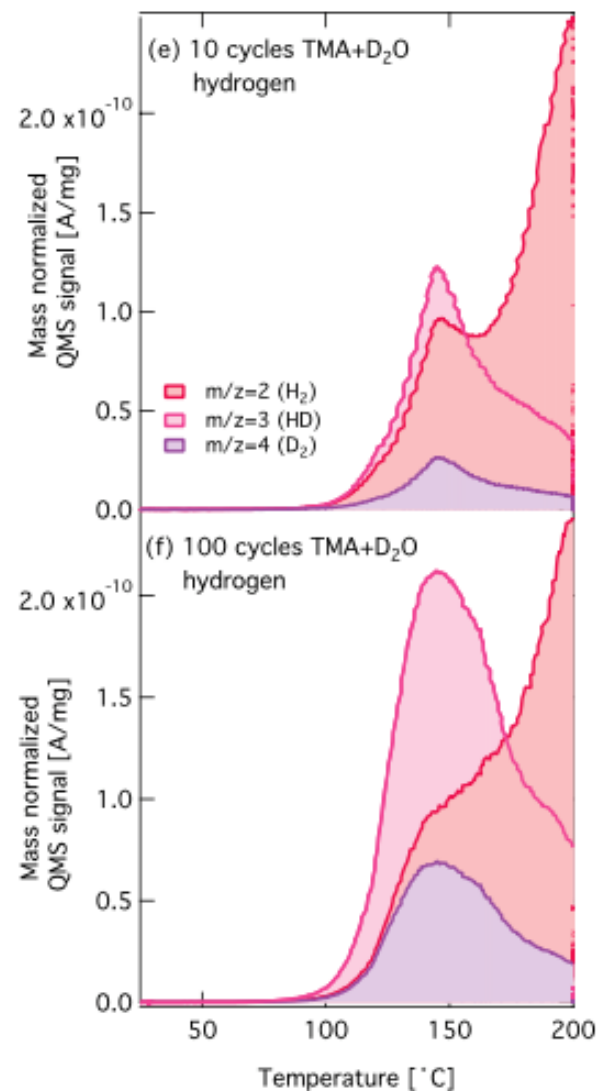
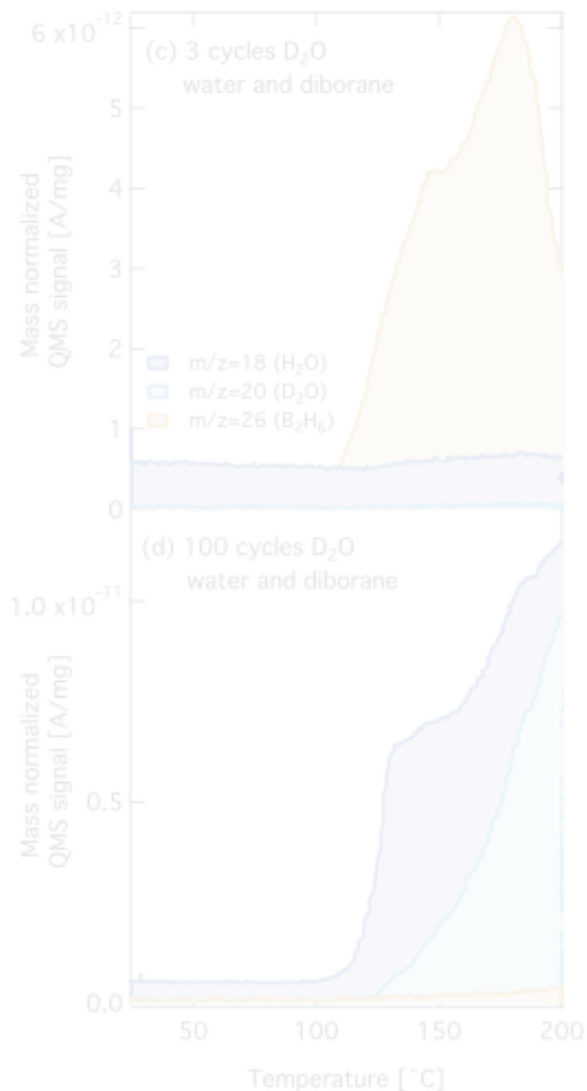
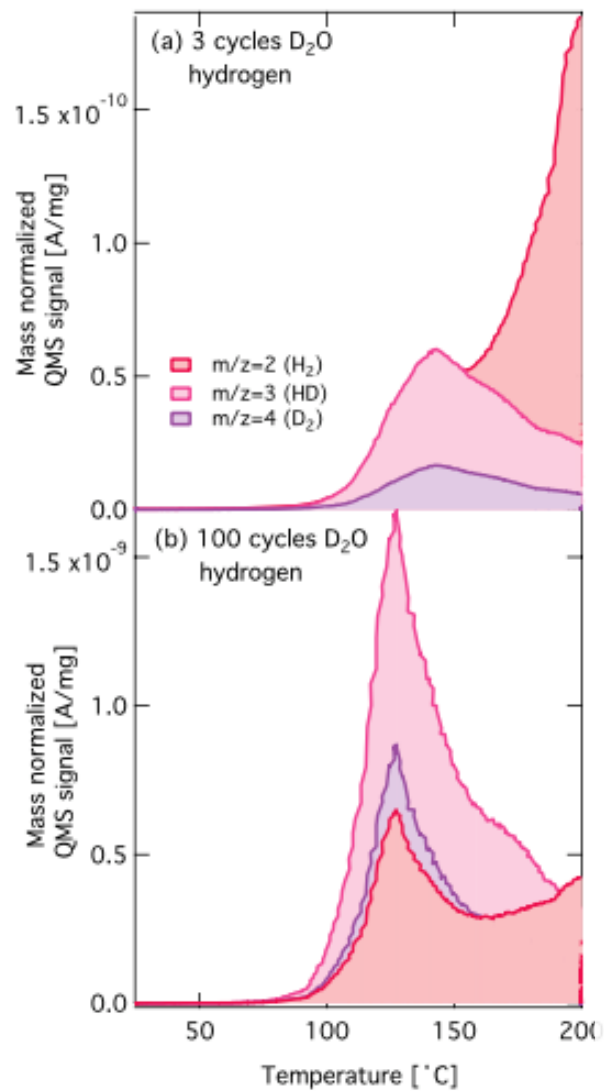


H_2O pulsing only

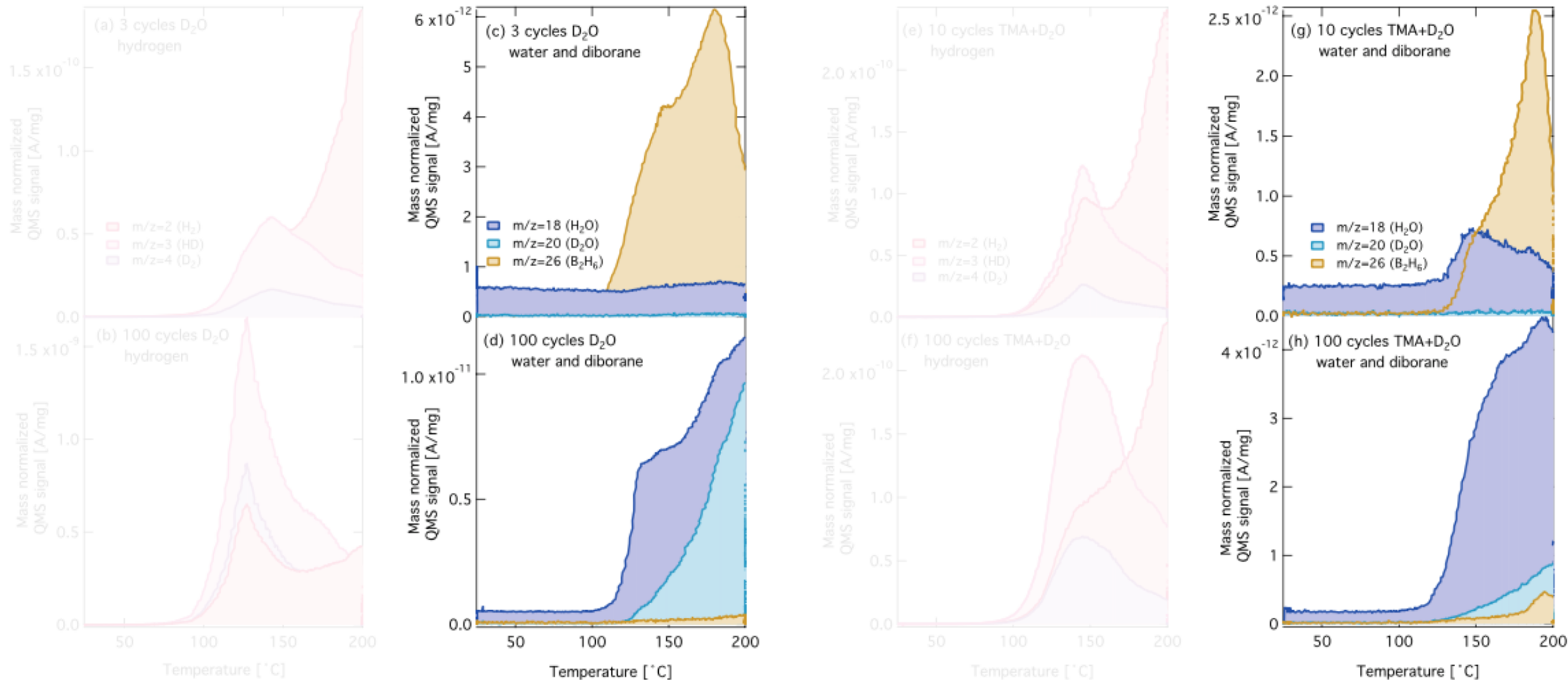


TMA pulsing only

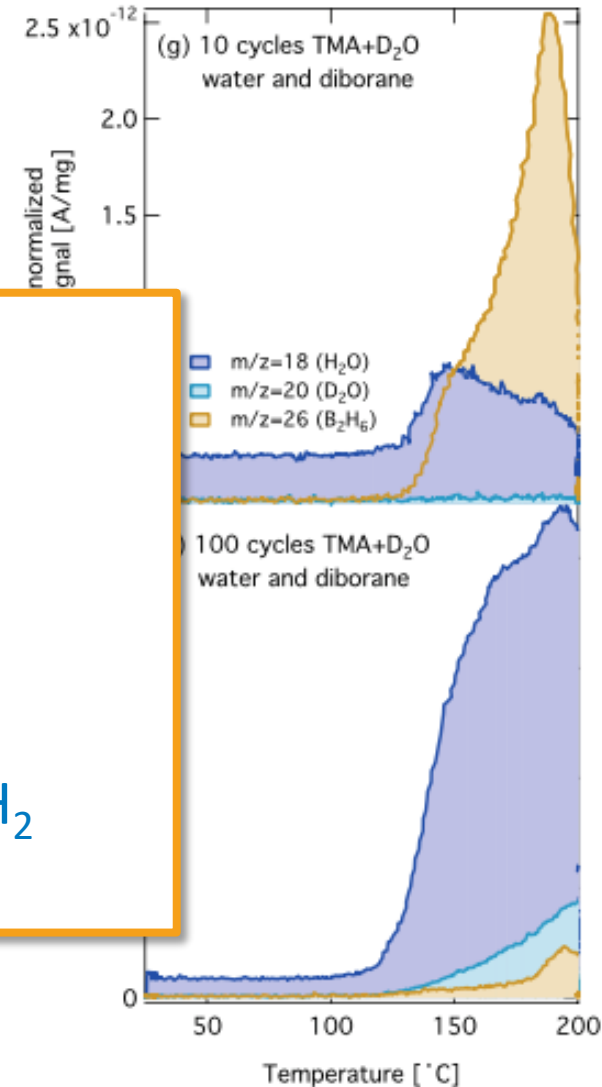
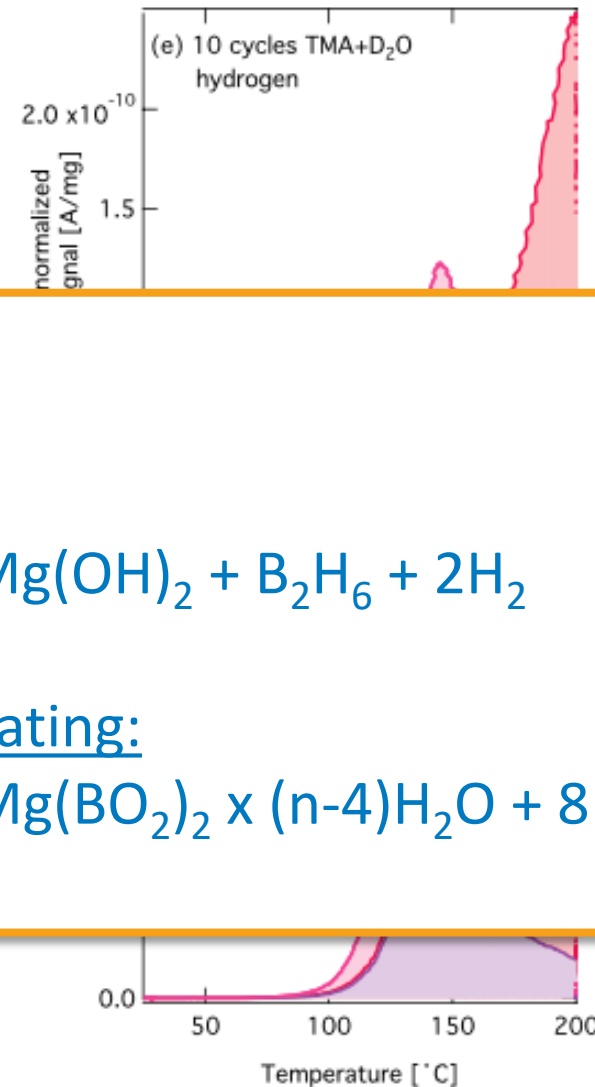
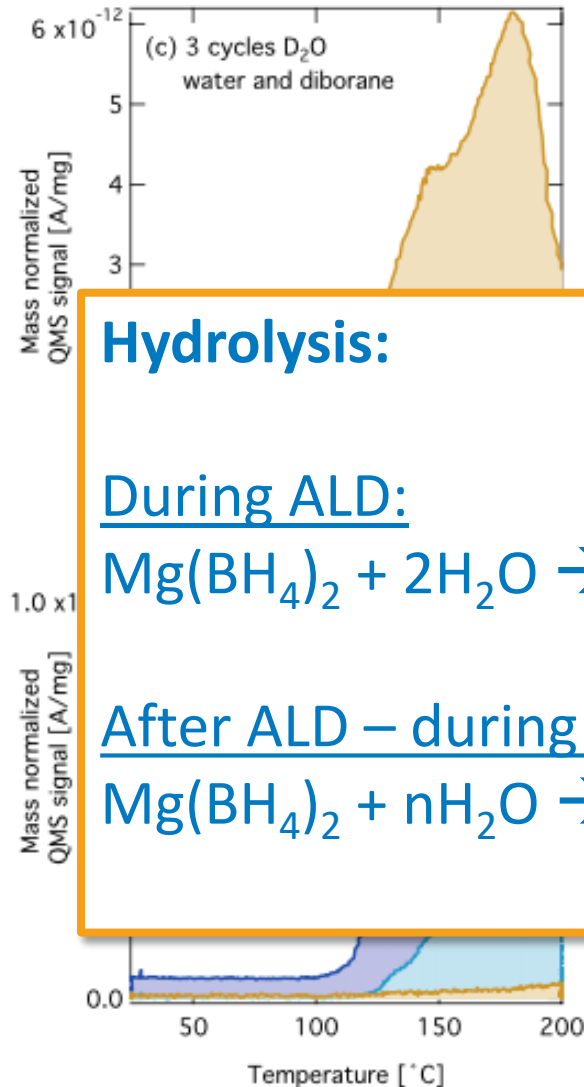
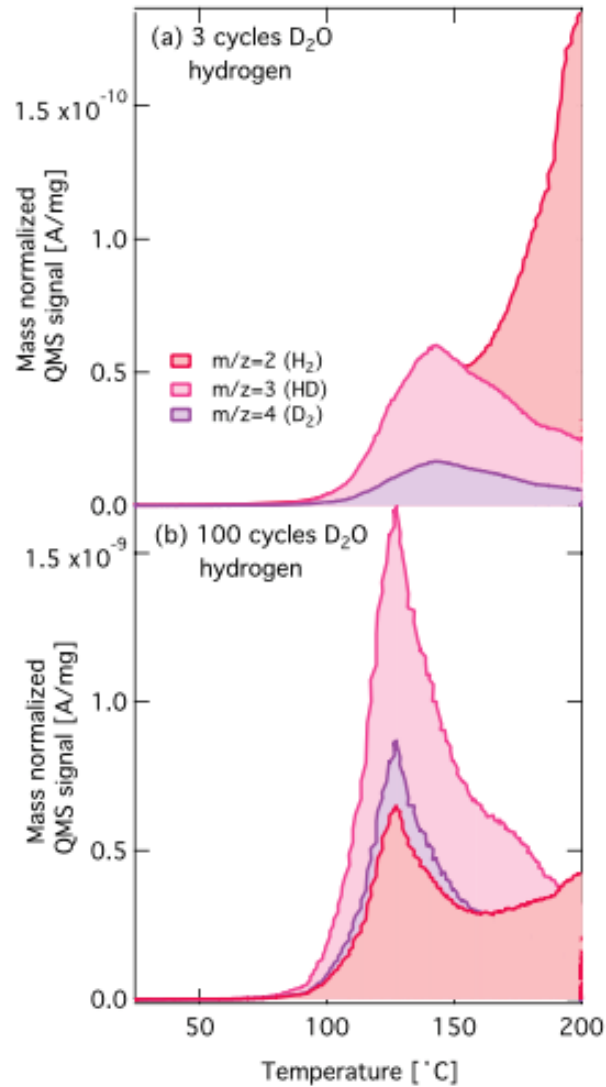
Mg(BH₄)₂: hydrolysis from TPD



Mg(BH₄)₂: hydrolysis from TPD



Mg(BH₄)₂: hydrolysis from TPD



Hydrolysis:

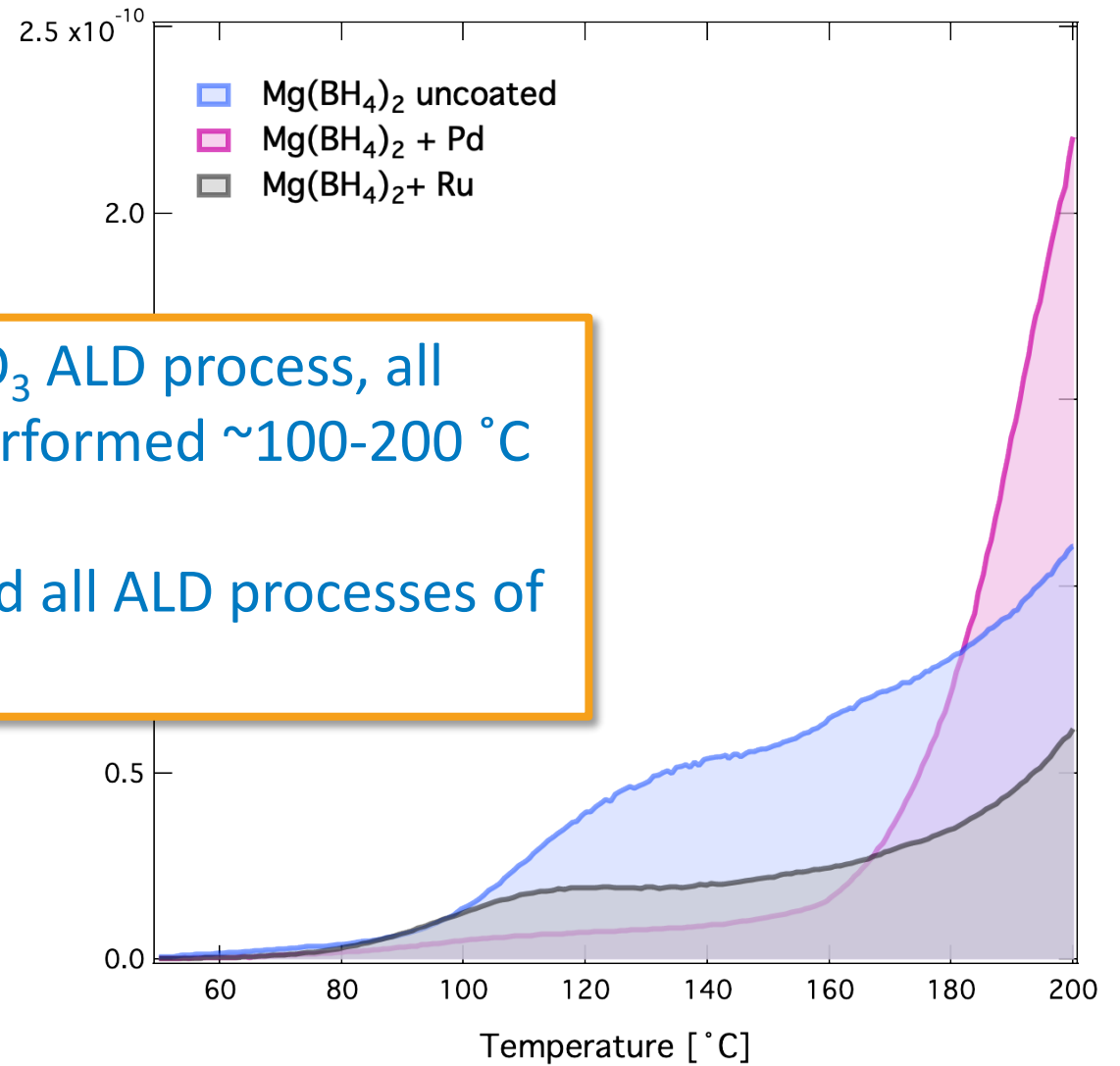
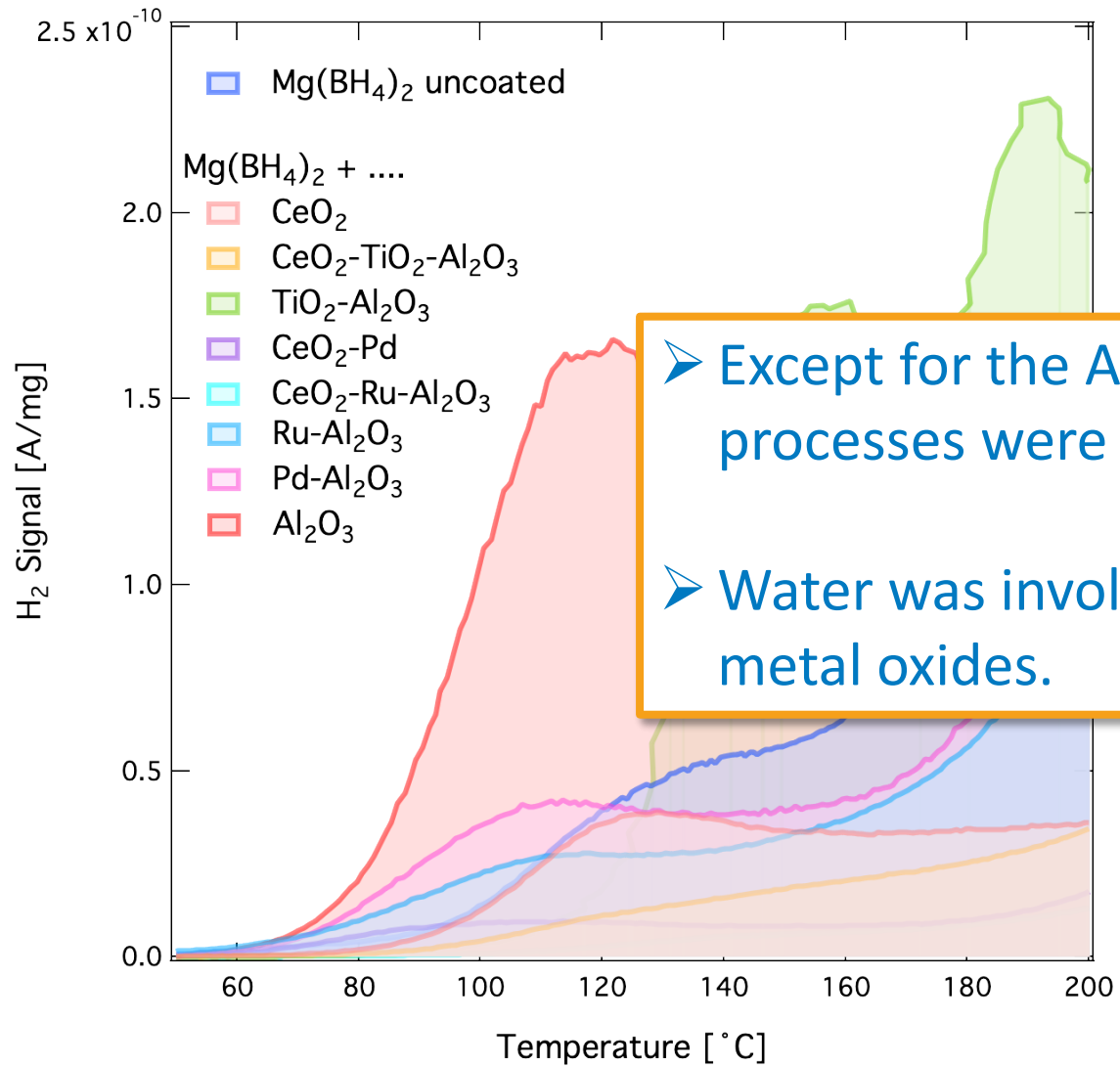
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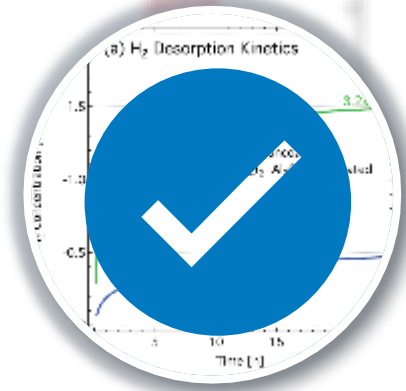
Mg(BH₄)₂ + ALD



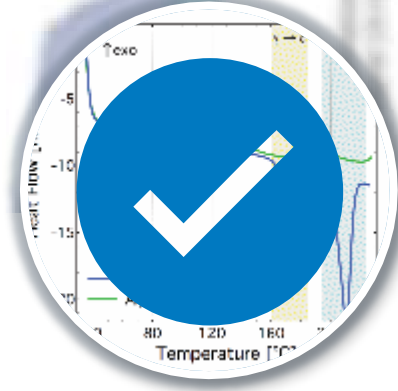
➤ Except for the Al₂O₃ ALD process, all processes were performed ~100-200 °C

➤ Water was involved all ALD processes of metal oxides.

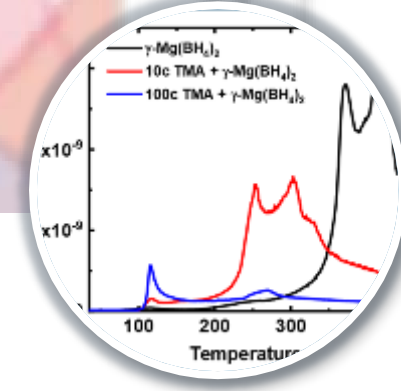
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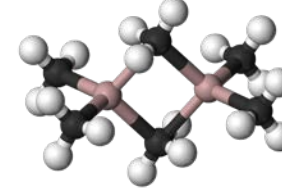


H_2O pulsing only

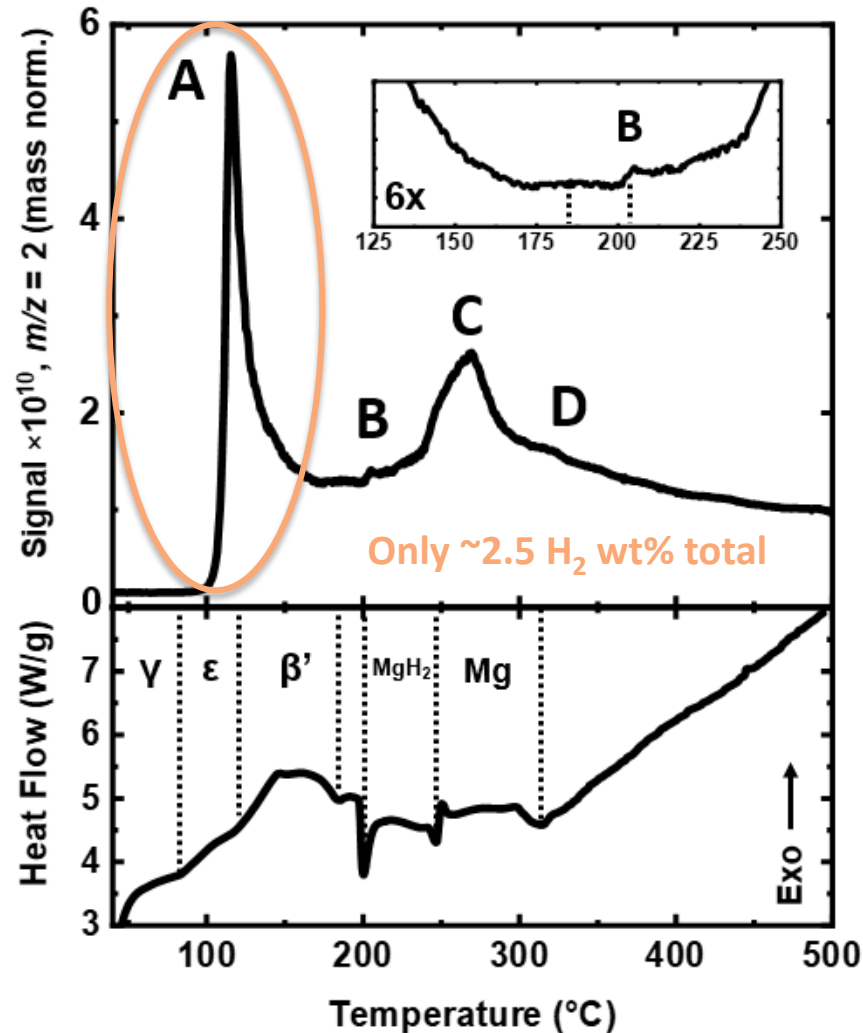


TMA pulsing only

100c TMA + γ -Mg(BH₄)₂



TPD/DSC with identical heating rates



Event A (~ 90 $^{\circ}\text{C}$)

- releases H₂ in the $\gamma \rightarrow \epsilon$ structural phase transformation region
- releases H₂ rapidly

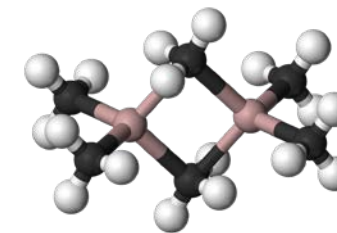
Event C coincides with MgH₂ \rightarrow Mg transition

- begins at 240 $^{\circ}\text{C}$, a reduction of over 125 $^{\circ}\text{C}$ compared to uncoated Mg(BH₄)₂

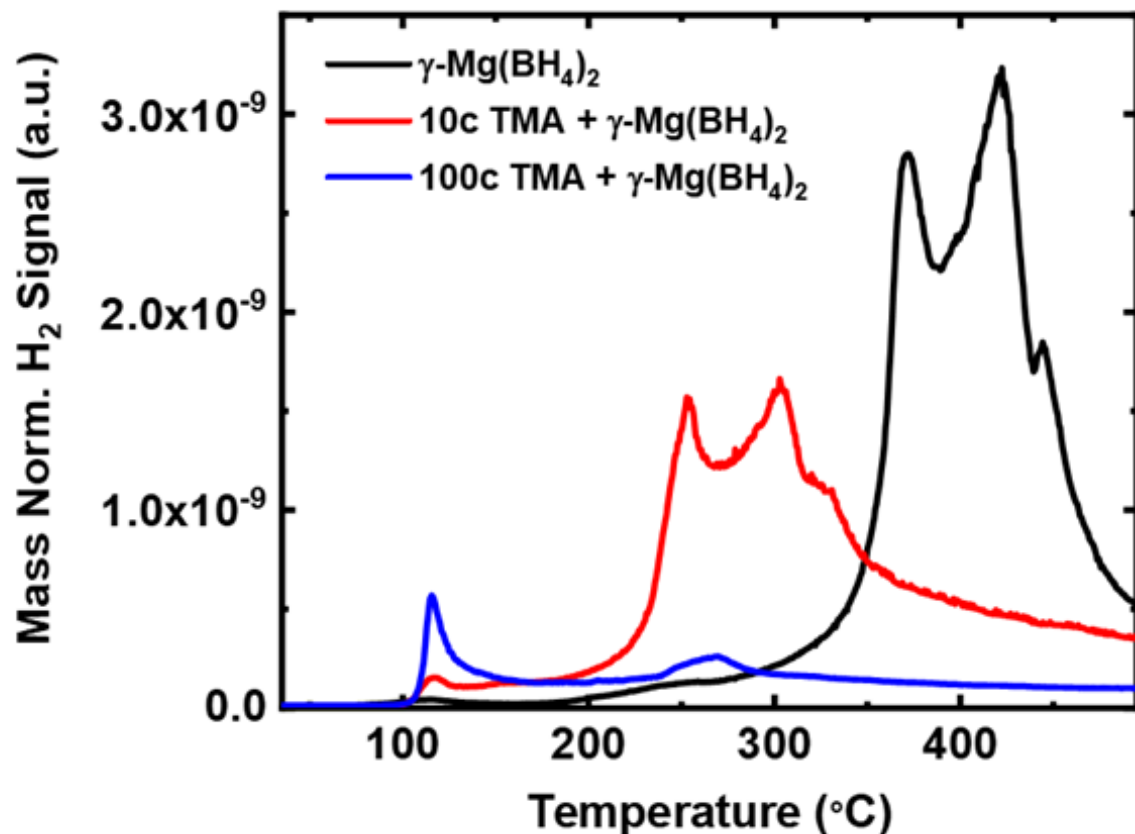
Low H₂ capacity

- ~ 0.6 H₂ wt% released below 175 $^{\circ}\text{C}$
- ~ 2.5 H₂ wt% from $20 - 500$ $^{\circ}\text{C}$

Volatile reaction products causing loss of H₂ capacity?



Temperature Programmed Desorption

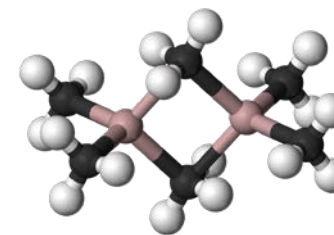


H₂ wt% from Integrated TPD Signal

	20-175 °C	20-250 °C	20-500 °C
γ -Mg(BH ₄) ₂	0.16	0.37	13.7
10c TMA	0.33	1.54	14.5
100c TMA	0.58	1.05	2.52

- 10c TMA sample exhibits full retention of native H₂ capacity between room temperature and 500 °C.
- H₂ desorption temperature is lowered by <100 °C.

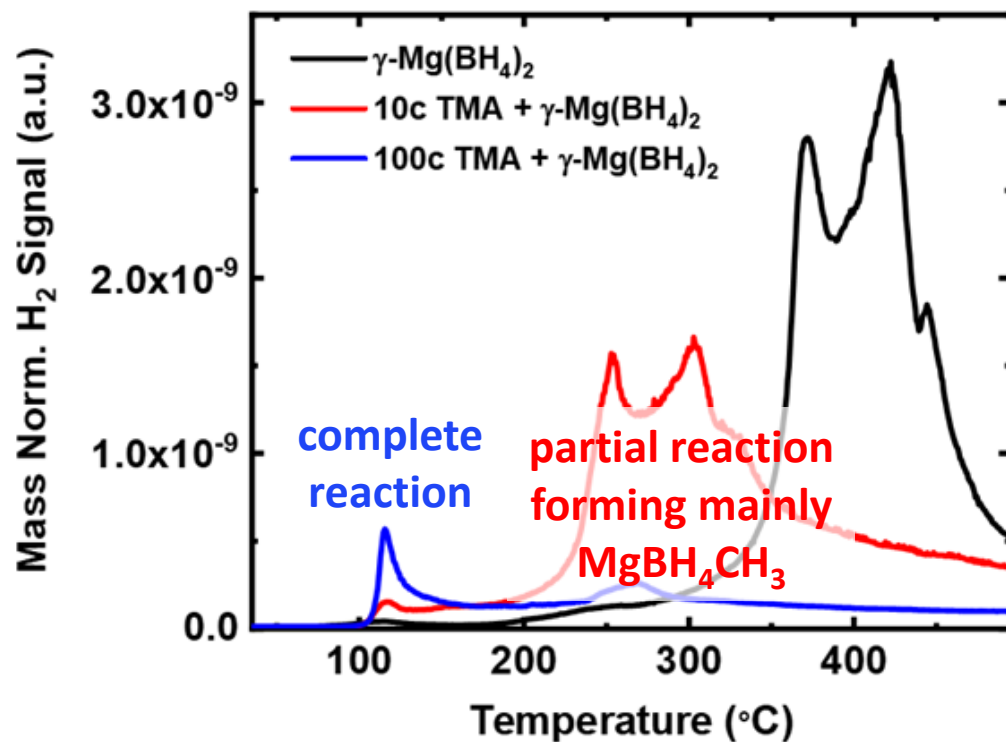
What Mechanism is Responsible for Improvement in H₂ Release?



vdW radius

BH₄⁻ = 2.05 Å

-CH₃ = 2.0 Å

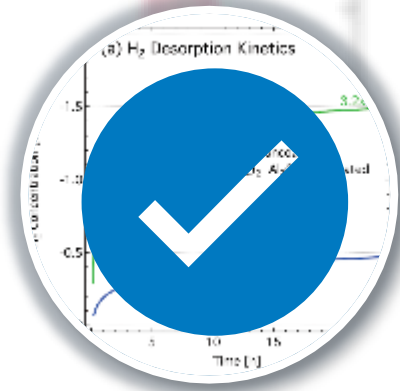


From ¹¹B, ²⁷Al NMR, DRIFTS, TPD:

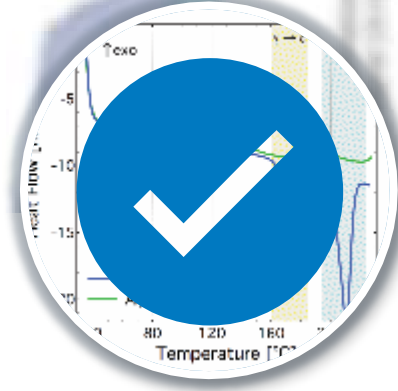
- No reaction with B – pure exchange of BH₄⁻ and CH₃
- No incorporation if Al-containing species



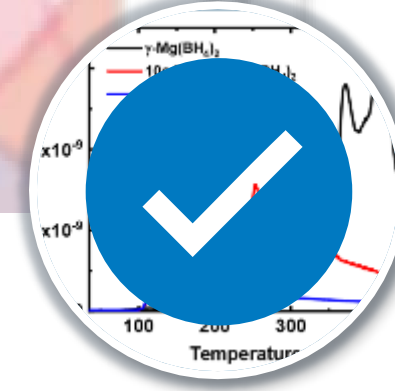
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TMA + H_2O



H_2O pulsing only



TMA pulsing only

Opportunities and Limitations for ALD on complex hydrides for H₂ storage

Short exposure to precursors

Exposure to 1 precursor can be sufficient

VdW radii of functional groups

Control of infiltration vs. coating

Room-temperature ALD processes

Need for more chemistries

Avoid the use of H₂O, oxygen precursors

Acknowledgements

The authors gratefully acknowledge research support from the Hydrogen Materials - Advanced Research Consortium (HyMARC), established as part of the Energy Materials Network under the U.S. Department of Energy, Office of Energy Efficiency and Renewable Energy, Fuel Cell Technologies Office, under Contract Number DEAC36-08-GO28308.

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